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## More is different: mobile ions improve the design tolerances of perovskite solar cells†

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Many recent advances in metal halide perovskite solar cell (PSC) performance are attributed to surface treatments which passivate interfacial trap states, minimise charge recombination and boost photovoltages. Surprisingly, these photovoltages exceed the cells' built-in potentials, often with large energetic offsets reported between the perovskite and transport layer semiconductor band edges – contradicting standard photovoltaic design principles. Here we show that this tolerance to energetic offsets results from mixed ionic/electronic conduction in the perovskite layer. Combining drift-diffusion simulations with experiments probing the current–voltage performances of PSCs as a function of ion distribution, we demonstrate that electrostatic redistribution of ionic charge reduces surface recombination currents at steady-state, increasing the photovoltage by tens to hundreds of millivolts. Thus, mobile ions can reduce the sensitivity of photovoltage to energetic misalignments at perovskite/transport layer interfaces, benefitting overall efficiency. Building on these insights, we show how photovoltaic design principles are modified to account for mobile ions.

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### Broader context

Metal halide perovskites are a class of semiconductors which can conduct both ionic and electronic charge and they are of interest as they can be used as the light absorbing layer in perovskite solar cells (PSCs) with high power conversion efficiencies (PCEs). The presence of mobile ionic defects in the perovskite layer changes the underlying device physics of PSCs compared to standard solar cells because both the ionic and electronic charge can redistribute in response to external electric fields. The implications of this ionic redistribution for how to design and optimise PSCs remains an open question. Most previous studies assume, *a priori*, that mobile ions are detrimental to solar cell performance. However, although mobile ions commonly reduce the short-circuit current densities of PSCs, here we show that they also lead to higher open-circuit voltages in the majority of commonly used device architectures, as well as increasing the choice of suitable contact materials which enable high PCEs to be achieved. Thus, the consequences of mobile ions on PCE can be either positive or negative, depending upon whether losses in the photocurrent can be compensated for by increases in the photovoltage.

### Introduction

Metal halide perovskites are a promising class of materials used as the active layer in next-generation photovoltaics. The highest performing, lab-scale, perovskite solar cells (PSCs) have achieved efficiencies of over 25%,<sup>1,2</sup> close to the best silicon photovoltaics. However, their underlying device physics is fundamentally different due to high densities of mobile halide vacancies in the perovskite layer.<sup>3–9</sup> The drawbacks of mobile ions have been well-discussed in the literature and consist in reduced extraction efficiency<sup>10–12</sup> and device instability.<sup>13–15</sup> However, the former can be avoided provided the diffusion length of electronic charge is sufficiently long<sup>16</sup> and the latter can be ameliorated by suitable passivation strategies.<sup>17–20</sup>

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Conversely, less consideration has been given to the question of whether there are conditions in which the presence of mobile ions may benefit PSCs. We believe that an answer to this question is of interest to the community since the low defect formation energies of metal halide perovskites makes it unlikely that mobile ionic species can ever be entirely removed.<sup>21,22</sup>

When considering the effect of mobile ions on device performance, it is necessary to consider their impact on both extraction and recombination. Although ionic field screening typically reduces extraction efficiency and thus short-circuit current density,<sup>10–12</sup> the effect of mobile ions on recombination and thus open circuit voltage ( $V_{OC}$ ) is less clear. Halide vacancies have been shown to form shallow defects meaning that their presence does not limit bulk electronic carrier lifetimes.<sup>22–25</sup> Consequently, their impact on  $V_{OC}$  will primarily depend upon how they affect device electrostatics and hence the electronic carrier distribution. Recombination at interfaces is thought to limit  $V_{OC}$  in even the best PSCs. It has been suggested that accumulation of ionic charge at perovskite/transport layer interfaces could reduce surface recombination currents by repelling minority electronic carriers, similar to the mechanism of field effect passivation used in silicon photovoltaics.<sup>8,26–31</sup> Indeed, recent simulations have shown that ion redistribution can significantly increase  $V_{OC}$ , and thus PCE, in situations where the built-in potential of the device falls below  $V_{OC}$ .<sup>31</sup> This is relevant to most PSCs, particularly high-efficiency devices, where values of  $V_{OC}$  routinely surpass the built-in potential (typically reported to lie in the range 0.8–1.0 V).<sup>32–34</sup>

Currently, there is no direct experimental confirmation of this effect, though it has been shown that the addition of alkali metal cations to methyl ammonium lead bromide increases  $V_{OC}$  due to an ionic modulation of the surface recombination current.<sup>35</sup> Conversely, recent experiments directly probing the effect of mobile ions on steady state performance have been interpreted as implying that mobile ions have no significant impact on steady-state  $V_{OC}$ .<sup>10,11</sup> Here, we address this apparent contradiction by proposing a novel approach to accurately assess the impact of mobile ions on PSC performance. Using this method, we measure the change in  $V_{OC}$  due to mobile ions for a variety of device architectures and perovskite compositions. In all cases, we find that mobile ions do increase  $V_{OC}$ , even in high efficiency devices showing negligible hysteresis. Additionally, the experiments are in excellent agreement with the predictions of our drift-diffusion simulations. We use these simulations to demonstrate that, in all cases of interest, the presence of mobile ions makes device performance more tolerant to energetic offsets between the conduction/valence band edges of the perovskite and its transport layers, at the cost of an increased sensitivity to the rate of interfacial recombination. This means that, although mobile ions do not *a priori* reduce maximum achievable PCEs, they do change the choice of optimal transport layer materials and we show how standard photovoltaic design principles should be modified to account for ionic redistribution.

## Experimental

### Drift-diffusion simulations

Device simulations were performed using Driftdiffusion, a software package designed to model one-dimensional, ordered semi-conductor devices which contain up to two species of mobile ions.<sup>36</sup> Further details of the simulation's assumptions and the protocols used can be found in the Extended Methods section of the ESI.†

### Device fabrication

**Triple cation devices (p-i-n structure).** These were fabricated as described in ref. 37.

#### MAPbI<sub>3</sub> devices (n-i-p structure)

**Materials.** All materials used were purchased from Sigma-Aldrich and used as received unless otherwise stated. Methylammonium iodide (MAI) was purchased from Greatcell Solar Ltd. 2,2',7,7'-Tetrakis [*N,N*-di(4-methoxyphenyl)amino]-9,9-spirofluorene (spiro-OMeTAD) was purchased from Luminescence Technology Corp. Glass substrates with a conducting layer of fluorine-doped tin oxide (FTO) of 8  $\Omega$  sq<sup>-1</sup> sheet resistance were purchased from Yingkou Shangneng Photoelectric Material Co., Ltd.

**Device substrate preparation.** The FTO glass substrates were pre-patterned by laser and then cleaned sequentially using Hellmanex III, deionised water (DI), acetone, ethanol and DI water, followed by a UV-Ozone plasma treatment for 15 minutes.

The compact TiO<sub>2</sub> layer was prepared by a sol-gel approach with a solution containing 0.23 M titanium isopropoxide and 0.013 M hydrochloric acid in isopropanol (IPA). 220  $\mu$ L of the solution was spin-coated dynamically on top of the substrate at 2000 rpm for 45 s, dried at 150 °C for 10 min and annealed at 500 °C for 45 min.

The SnO<sub>2</sub> layer was prepared in a 1:1 solution with deionised water, stirred, and filtered through a hydrophilic PTFE filter. 50  $\mu$ L of the prepared solution was dynamically spin-coated at 4000 rpm for 30s followed by annealing at 150 °C for 30 min.

Devices with the C<sub>60</sub>-BA (4-(1',5'-dihydro-1'-methyl-2'-H-[5,6]fullereno-C60-1h-[1,9-c]pyrrol-2'-yl)benzoic acid) interface used a 0.5 mg mL<sup>-1</sup> solution in chlorobenzene (CB). This solution was stirred and 50  $\mu$ L was dynamically spin-coated followed by an annealing step at 100 °C for 5 min. Following the SAM layer a 0.2 wt% IPA solution of Aluminium oxide (Al<sub>2</sub>O<sub>3</sub>) nanoparticles (Sigma-Aldrich, < 50 nm particle size, 20 wt% in IPA) was deposited on top of the C<sub>60</sub>-BA. Utilising 50  $\mu$ L and spincoating at 2000 rpm for 30 s, samples were then dried at 120 °C for 5 min for improved nucleation of the perovskite on the SAM layer.

Following this, all substrates were immediately transferred to a nitrogen-filled glovebox.

**Device perovskite layer deposition.** The perovskite solution methyl ammonium lead iodide (MAPI) was synthesised using a 1:1 solution of methyl ammonium iodide (MAI) and lead



iodide (PbI<sub>2</sub>) in a 4 : 1 dimethylformamide (DMF): dimethylsulfoxide (DMSO) solution and allowed to dissolve on a hot plate before use. The perovskite was deposited by dynamic spin coating at 1000 rpm for 10 s and then 5000 rpm for 30 s. With 50  $\mu\text{L}$  of the filtered MAPI solution being deposited at the 5 s mark, followed by 300  $\mu\text{L}$  of filtered chlorobenzene anti-solvent. After deposition, the samples were allowed to dry on a clean cloth for 15 minutes followed by annealing at 100  $^{\circ}\text{C}$  for 15 minutes.

**Solar cell finalisation.** For the hole transporting layer, 50  $\mu\text{L}$  of a Spiro-OMeTAD solution was spin-coated on the perovskite layer at 4000 rpm for 30 s with an acceleration of 2000 rpm. Spiro-OMeTAD (90 mg mL<sup>-1</sup> in chlorobenzene) was doped with 23  $\mu\text{L}$  of Bis(trifluoromethane)sulfonimide lithium salt (LiTFSI) stock solution (520 mg in 1 mL acetonitrile (ACN)), 5  $\mu\text{L}$  of FK-209 (Cobalt(III) salt) stock solution (180 mg in 1 mL ACN) and 35.5  $\mu\text{L}$  of 4-*tert*-butylpyridine (tBP) prior to spin coating. Finally, a 40 nm thick gold (Au) electrode was thermally deposited under vacuum to complete the devices. The deposition rate was 0.1 nm s<sup>-1</sup>. Devices used in the Stabilise and Pulse rig were sealed using an epoxy adhesive mixture and a glass slide before measuring.

### Solar cell characterisation

All solar cell characterisation was conducted at room temperature under ambient conditions.

**Triple cation devices (p-i-n structure).** *JV* Scans were measured by a Keithley 2400 source measure unit coordinated with computer and self-made LabView program. The measurement was conducted under 1 sun illumination and AM1.5G spectrum generated by ABET Sun 2000 solar simulator through a shadow mask to define the active area (0.075 cm<sup>2</sup>). The illumination intensity was calibrated by Enli PVM silicon standard reference cell. The reverse scan was from 1.2 V to -0.2 V while the forward scan was from -0.2 V to 1.2 V. The change of scan speed was achieved by changing scan step and delay time between data points. Measurement details for different *JV* scanning speeds are shown in the following table:

Scan speed	Scan step (V)	Delay time (ms)
Normal	0.03	10
Fast	0.05	0.1
Slow	0.005	500

**MAPbI<sub>3</sub> devices (n-i-p structure).** The *JV* characteristics were carried out under one sun (AM 1.5) illumination using a Wavelabs Sinus-70 AAA solar simulator and measured using a Ossila Source Meter Unit. The devices were pre-biased at 1.3 V for 10 s with 1 sun illumination and measured in the reverse then forward scan direction in 0.2 V s<sup>-1</sup> steps. Non-reflective metal masks with an aperture area of 0.1 cm<sup>2</sup> were used to define the illumination area of the devices.

### Stabilise and pulse measurements

Initially, *JV* curves for each device were measured under standard AM1.5 simulated sunlight, as described previously in the Experimental section. Devices were then immediately transferred to the home-built Stabilise and Pulse setup. Here, a Cree High Power white LED was used as the light source, the intensity of which was calibrated to match the device's measured short circuit current density. Voltage pulses were provided by an Ossila Source Meter Unit. Each voltage pulse had a duration of approximately 40 ms and the device was stabilised for 1 s between the voltage pulses *i.e.*, a duty cycle of around 5%. The source delay was set to 1  $\mu\text{s}$ , meaning that the current value was acquired approximately 1  $\mu\text{s}$  after the arrival of the voltage pulse, though we note that the returned value is the average over the following 15  $\mu\text{s}$ . When changing the bias voltage, 50 mV step increments were used with the stabilisation period being a minimum of 120 s, though in some cases this was extended to obtain a stable current output. We note that devices using the alloyed perovskite required a longer stabilisation period than those using MAPI. Consequently, the measurements were performed at approximately 0.5 Suns to prevent degradation during the significantly longer Stabilise and Pulse protocol. Further details of the analysis of the Stabilise and Pulse measurements is given in the Extended Methods section of the ESI.†

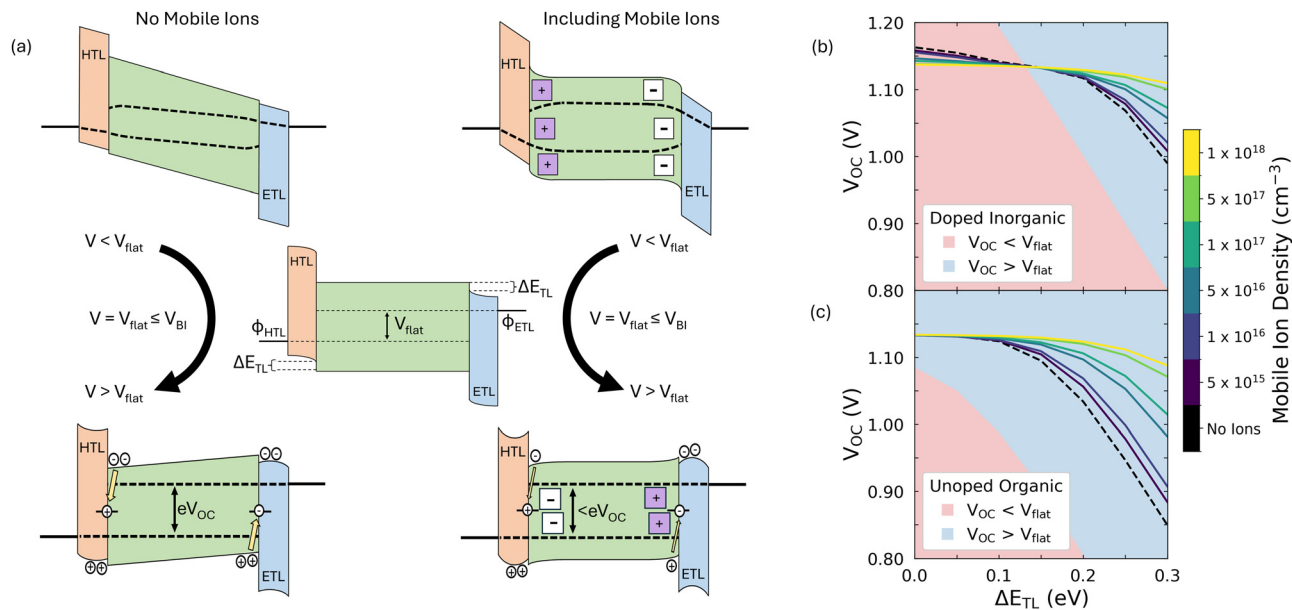
## Results and discussion

### Theory and simulation

Field effect passivation is a technique commonly applied in silicon photovoltaics and involves the insertion of a layer of static ionic charge between the silicon active layer and its transport layers.<sup>38</sup> This ionic charge serves to repel minority carriers and thus reduce rates of surface recombination, improving photovoltage. It has been suggested that the presence of mobile ionic charge in PSCs should have similar consequences for steady state device performance.<sup>29-31</sup> We illustrate this in Fig. 1a, which shows the impact of mobile ions on solar cell band diagrams for applied voltages below (top row), equal to (centre) and above (bottom row) the flat band condition across the active layer,  $V_{\text{flat}}$ .

The presence of mobile ions leads to a smaller change in voltage across the active layer and greater changes in voltage across the transport layers (see Fig. S1, ESI†). This means that, for a given applied voltage above (below)  $V_{\text{flat}}$ , the accumulation (depletion) of minority carriers at the perovskite/transport layer interfaces will be greater when no mobile ionic charge is available to electrostatically substitute for the electronic carriers. Thus, the presence of mobile ions will reduce surface recombination currents at applied voltages greater than  $V_{\text{flat}}$  as long as the accumulation/depletion of ionic charge at interfaces does not lead to a degradation of the transport layers with a corresponding increase in the rate of interfacial recombination. This condition is applicable when degradation has not yet occurred or where interfaces have been well passivated so that degradation is prevented. We note that the latter criteria must





**Fig. 1** (a) Illustration of the impact of mobile ions on solar cell band diagrams. In these figures, we assume undoped organic transport layers.  $\Delta E_{\text{TL}}$  is defined as the energetic offset between the perovskite's conduction (valence) band and that of the ETL (HTL). The built-in potential ( $V_{\text{Bi}}$ ) is defined at the difference in the equilibrium values of the anode and cathode work function ( $\phi_{\text{HTL}}$  and  $\phi_{\text{ETL}}$ , respectively). In the central panel, where the applied voltage is equal to the flat band condition in the active layer,  $V_{\text{flat}}$ , the band diagrams of devices with and without mobile ions look identical. Note how, in this example, the residual band bending in the undoped contacts means that  $V_{\text{flat}} < V_{\text{Bi}}$ . In the bottom row, we illustrate how band bending due to the redistribution of mobile ions can reduce minority carrier accumulation at interfaces, when compared to an equivalent device with no ions. This reduces the rate of interfacial recombination for a given applied voltage, increasing the device's open circuit voltage ( $V_{\text{OC}}$ ). Figures (b) and (c) show the dependence of  $V_{\text{OC}}$  on  $\Delta E_{\text{TL}}$  for doped inorganic and undoped organic parameter sets, respectively. The red and blue shaded regions indicate where  $V_{\text{OC}}$  is less than and greater than  $V_{\text{flat}}$ , respectively.

apply for any commercially viable PSC technology, meaning that the impact of mobile ions on steady state performance will only become more important as passivation strategies improve.

We stress here that the ability for one (or more) mobile ionic species to modulate surface recombination currents in this way rests on two key assumptions. First, the ionic species must not act as a significant recombination centre. This is likely the case for most types of common ionic defects in metal halide perovskites,<sup>22–25</sup> with the significant exception of halide interstitials.<sup>25,39</sup> Secondly, we assume that the mobile ionic charge does not permeate the transport layers. This would be expected to negatively affect device stability<sup>13,14</sup> but can be avoided by suitable choices of interfacial blocking layers.<sup>17–20</sup> Thus, although we refer to halide vacancies within this text, we would expect our results to be applicable to any mobile ionic species which satisfies the above criteria. Additionally, we have verified that our results are still valid if there are two species of mobile ionic charge present in the perovskite (e.g., halide vacancies and  $\text{H}^{+40}$ ), as we show in Supplementary Note One (ESI†).

To systematically explore how the choice of transport layers affects  $V_{\text{flat}}$  and thus the influence of ions on  $V_{\text{OC}}$ , we simulated current density–voltage ( $J$ ) scans on three-layer, symmetric PSCs (device structure illustrated in Fig. 1a) and contrasted the behaviour with and without the inclusion of a mobile ionic species for two different transport layer parameter sets (see the Extended Methods in the ESI† for full details of the simulation

protocol). In the ‘doped inorganic’ parameter set, we considered materials which have a high intrinsic carrier density, mobility, and permittivity. These properties are representative of n-type metal oxides, such as  $\text{SnO}_2$ ,<sup>41–43</sup> and doped Spiro-OMeTAD,<sup>44,45</sup> though the latter, being an organic material, does not have a high permittivity. In the ‘undoped organic’ parameter set, we considered materials which are intrinsic semiconductors, with a low mobility and permittivity. These properties reflect organic semiconductors which are commonly used as the transport layers in p–i–n PSCs (e.g.,  $\text{C}_{60}$ , PCBM, PTAA).<sup>46,47</sup> The parameters of the transport layers are summarised in Table S1 and all other parameters are given in Table S2 (ESI†).

When choosing transport layer materials, two properties are commonly seen as having the largest impact on device performance: transport layer energetic offset,  $\Delta E_{\text{TL}}$  (as defined in Fig. 1a) and surface recombination velocity,  $\nu_s$ .<sup>12,28,48,49</sup> The latter parameter determines the rate of interfacial recombination at the perovskite/transport layer interfaces and is important because this process is thought to limit  $V_{\text{OC}}$  in the majority of the highest performing PSCs, especially those which use  $\text{C}_{60}$  as the ETL.<sup>49–51</sup> As  $\Delta E_{\text{TL}}$  and  $\nu_s$  have the potential to be easily tuned by material selection<sup>12</sup> and the use of interfacial passivation strategies,<sup>46</sup> respectively, we investigated the effect of mobile ions on  $V_{\text{OC}}$  over an experimentally relevant range of these parameters. In the main text, we consider the cases where both parameters are varied symmetrically (i.e., take the same



value at both perovskite/transport layer interfaces) as this simplifies the description while maintaining most of the relevant device physics. However, special care must be taken when there is significant difference between the values of  $\Delta E_{\text{TL}}$  at the perovskite/ETL and perovskite/HTL interfaces as there will not be a single voltage at which the ion population is uniformly distributed in such cases. This is because the accumulation and depletion regions on each side of the perovskite invert at different applied potentials due to charge carrier imbalances in the active layer.<sup>28</sup> We provide a brief discussion of such cases in Supplementary Note Two (ESI<sup>†</sup>), and a comprehensive mathematical treatment can be found in Cordoba and Taretto.<sup>31</sup>

Our results for varying  $\Delta E_{\text{TL}}$  are shown in Fig. 1b and c for the doped inorganic and undoped organic parameter sets, respectively. We observe that the presence of mobile ions can increase  $V_{\text{OC}}$  for both parameter sets and that the size of this effect increases with both  $\Delta E_{\text{TL}}$  and the mobile ionic density. A result of this is that a high mobile ion density makes the value of  $V_{\text{OC}}$  less dependent upon the energetic alignment between the perovskite and the transport layers. These observations are natural consequences of the mechanism shown in Fig. 1a. First, the improvement in  $V_{\text{OC}}$  due to mobile ions is greater in a device with a higher mobile ion density as there is more ionic charge available to electrostatically compensate minority electronic charge at the interfaces with the transport layers. Secondly, ions are more beneficial to  $V_{\text{OC}}$  in devices with larger values of  $\Delta E_{\text{TL}}$  as large values of  $\Delta E_{\text{TL}}$  restrict  $V_{\text{BI}}$ , resulting in lower values of  $V_{\text{flat}}$  (see Fig. S2, ESI<sup>†</sup>). Only once  $V_{\text{OC}}$  lies above  $V_{\text{flat}}$  do ions become beneficial to  $V_{\text{OC}}$  (compare the impact of mobile ions in the red and blue regions of Fig. 1b and c) as they can mitigate the high rates of surface recombination which are present in devices where there is a reverse field in the active layer and no mobile ions. Thus, ions facilitate a decoupling of  $V_{\text{OC}}$  and  $V_{\text{flat}}$ .

Fig. 1b and c also demonstrate that ions result in a larger increase in  $V_{\text{OC}}$  in the case of devices with undoped, organic transport layers. This is because these transport layers result in lower  $V_{\text{flat}}$  values for a given  $\Delta E_{\text{TL}}$ , despite both sets of simulations using the same values of  $V_{\text{BI}}$ . We can understand this by considering what determines  $V_{\text{flat}}$  in each configuration. In the doped, inorganic case, we find that  $V_{\text{flat}}$  is dictated by the offset in the Fermi levels of the transport layers (although we note that it falls below this value when there are significant injection barriers from the electrodes into the transport layers, as shown in Fig. S2, ESI<sup>†</sup>). In contrast, for symmetric, undoped interlayers,  $V_{\text{flat}}$  can be found by numerically solving the implicit equation (see Supplementary Note Three, ESI<sup>†</sup>)

$$w_{\text{TL}} = \sqrt{\frac{2\varepsilon\varepsilon_0 k_{\text{B}} T}{n_0 e^2}} \exp\left(\frac{e(V_{\text{BI}} - V_{\text{flat}})}{4k_{\text{B}} T}\right) \times \left[\frac{\pi}{2} - \arcsin\left(\exp\left(\frac{-e(V_{\text{BI}} - V_{\text{flat}})}{4k_{\text{B}} T}\right)\right)\right] \quad (1)$$

where  $w_{\text{TL}}$  is the transport layer width,  $\varepsilon_0$  the permittivity of free space,  $\varepsilon$  the transport layer permittivity,  $k_{\text{B}}$  the Boltzmann constant,  $T$  the temperature and  $n_0$  the carrier density in the

transport layer at the interface with the electrode, which depends upon the transport layer density of states and the offset between the electrode work function,  $\phi$ , and the relevant band edge of the transport layer (*i.e.*, for the HTL,  $n_0 = N_{\text{v}} \exp[(E_{\text{v}} - \phi)/k_{\text{B}} T]$ ). We note that this equation only depends upon transport layer properties, which implies that using undoped interlayers can result in a substantial reduction in the value of  $V_{\text{flat}}$ , regardless of the presence of mobile ions. However, when mobile ions are present, they can compensate for this reduction in  $V_{\text{flat}}$  and allow devices with undoped transport layers to achieve  $V_{\text{OC}}$  values almost as high as their doped counterparts.

In addition to these positive impacts, varying  $\nu_{\text{S}}$  allowed us to identify two regimes where the presence of mobile ions does not improve  $V_{\text{OC}}$  (see Fig. S3 and S4, ESI<sup>†</sup>). First, mobile ions will not improve  $V_{\text{OC}}$  when  $V_{\text{OC}}$  is less than  $V_{\text{flat}}$  since then the changes in voltage in the perovskite layer are positive. In this situation, the presence of mobile ions results in a higher minority carrier density at the transport layer interfaces than is the case without mobile ions, and so surface recombination losses are greater for the same applied voltage, reducing  $V_{\text{OC}}$ . Secondly, for devices operating in the high injection limit, mobile ions do not improve  $V_{\text{OC}}$  when recombination losses are dominated by bulk processes. This is because, assuming midgap trap states and equal carrier lifetimes, the rate of Shockley–Read–Hall recombination is maximised when the electronic carrier densities are equal (*i.e.*,  $n \approx p$ ). This is true in a greater fraction of the perovskite layer when mobile ions are present as they screen the electric field, resulting in more uniform carrier distributions and thus a greater overlap of the electrons and hole populations. Consequently, the rate of bulk recombination will be higher in a device with a mobile ionic species than in an equivalent device without ions causing the former to have a lower  $V_{\text{OC}}$ .

### Experimental validation of the impact of mobile ions on open-circuit voltage

With these theoretical expectations in hand, we now seek to test the predictions of our drift-diffusion simulations experimentally. To do this, we make use of the Stabilise and Pulse technique described by Hill *et al.*,<sup>52</sup> with full details of the measurement protocol given in the Methods section. In brief, this technique allows one to measure *JV* curves for PSCs with the ions frozen in a configuration determined by the stabilisation voltage,  $V_{\text{bias}}$ . This is achieved by first holding the PSC at  $V_{\text{bias}}$  for a stabilisation period, during which the mobile ions reach quasi-steady state (QSS) for the chosen bias condition. Then, the current output is measured for a range of short pulse voltages superimposed on  $V_{\text{bias}}$ . By plotting the current during the pulses *versus* the pulse voltages, a *JV* curve can be reconstructed for the steady state ion distribution defined by  $V_{\text{bias}}$  since there will be negligible ionic redistribution if the pulses are sufficiently short and the duty cycle small enough, *i.e.*, <10%.<sup>29,52–54</sup> If  $V_{\text{bias}}$  is chosen to equal  $V_{\text{flat}}$  and assuming an energetically symmetric device, the reconstructed *JV* curve will be the one obtained with the ions distributed uniformly



across the active layer, and thus equivalent to the  $JV$  curve which would be obtained for the same device structure, but without a mobile ionic species.

To estimate  $V_{\text{flat}}$ , we performed Stabilise and Pulse measurements at multiple values of  $V_{\text{bias}}$  and analysed the change in gradient of the  $JVs$  around  $V_{\text{OC}}$ , as detailed in ref. 52 (further details given in the Methods). As noted above, in situations where there are asymmetric energetic offsets to the transport layers, there will not be a single value of  $V_{\text{flat}}$ . Thus, we have performed additional simulations to verify that the Stabilise and Pulse technique can still extract the 'ion-free' device performance in such cases, and these are discussed in Supplementary Note Two (ESI<sup>†</sup>). Lastly, by plotting the average currents from the last 30 seconds of the stabilisation period *versus*  $V_{\text{bias}}$  we can determine the  $JV$  curve with the ions at QSS (see Fig. S5, ESI<sup>†</sup>).<sup>55,56</sup> By combining the QSS  $JV$  and the reconstructed Stabilise and Pulse  $JV$  (SaP  $JV$ ) evaluated at  $V_{\text{bias}} \approx V_{\text{flat}}$ , we can experimentally determine the  $JV$  curves of a given device with and without a mobile ionic species to evaluate the effect of ions on device performance. We note this protocol is an improvement upon those used previously in the literature as we make no assumptions about the value of  $V_{\text{flat}}$ , but instead extract it from the experimental data.<sup>10,11,57</sup> This allows for a more accurate assessment of the performance of the device in the absence of a mobile ionic species.

Based on our simulations, we hypothesise that we will see a smaller impact of mobile ions on  $V_{\text{OC}}$  if we reduce the fraction of the total recombination which occurs at perovskite/transport

layer interfaces (see Fig. S2 and S3, ESI<sup>†</sup>). To test this experimentally, we measured the change in  $V_{\text{OC}}$  due to ions in n-i-p PSCs with and without a self-assembled monolayer (SAM) between the perovskite and the ETL. The device stack was Au/Spiro-OMeTAD/MAPbI<sub>3</sub>/(SAM)/TiO<sub>2</sub>/FTO (see Fig. S6, ESI<sup>†</sup>), where methyl ammonium lead iodide (MAPI) was chosen since, although it limits our maximum device efficiency, it has been widely reported to have a high mobile ion density ( $10^{17}$ – $10^{19}$  cm<sup>-3</sup>).<sup>21,58–60</sup> Our simulations show that this will maximise any effect of mobile ions on  $V_{\text{OC}}$ , making such an effect easy to detect experimentally. For our SAM, we used the benzoic acid derivative of C<sub>60</sub> (C<sub>60</sub>-BA) which has been shown to enhance the efficiency of electron extraction and to passivate shallow trap states at the perovskite/TiO<sub>2</sub> interface.<sup>61–63</sup> Device parameters with and without C<sub>60</sub>-BA are summarised in Tables S3 and S4 (ESI<sup>†</sup>).

In Fig. 2a and b, we show the results of Stabilise and Pulse measurements performed on devices without and with C<sub>60</sub>-BA, respectively (relevant solar simulator data is shown in Fig. S7, ESI<sup>†</sup>). The Stabilise and Pulse data were analysed to extract values for  $V_{\text{flat}}$  as shown in Fig. S8 (ESI<sup>†</sup>). When averaged over all measured devices,  $V_{\text{flat}}$  was found to be  $0.66 \pm 0.02$  V for the devices without C<sub>60</sub>-BA and  $0.73 \pm 0.02$  V for those with C<sub>60</sub>-BA (for details of all measured  $V_{\text{flat}}$  values, see Tables S3 and S4, ESI<sup>†</sup>). We note that, although our values of  $V_{\text{flat}}$  are low compared to some others in the literature, many literature values were obtained from Mott-Shockley analysis, the reliability of which has been challenged when applied to PSCs.<sup>64–66</sup>

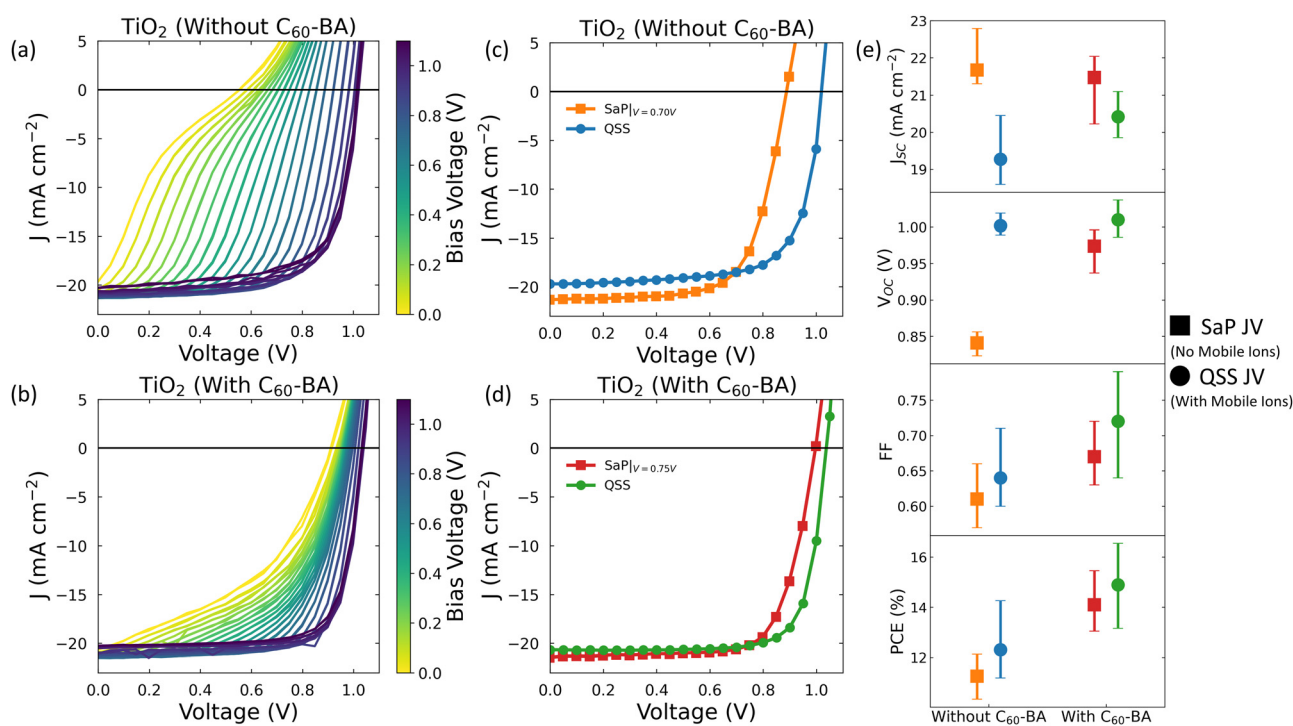


Fig. 2 Stabilise and Pulse measurement for the devices (a) without and (b) with C<sub>60</sub>-BA. The quasi-steady state (QSS)  $JVs$  and Stabilise and Pulse (SaP)  $JVs$  evaluated at  $V \approx V_{\text{flat}}$  for the TiO<sub>2</sub> devices (c) without and (d) with C<sub>60</sub>-BA. (e) Summary of the  $JV$  parameters extracted from the SaP  $JVs$  and QSS  $JVs$  for all measured devices. Error bars indicate the range of measured values.



**Table 1** Summary of the experimental and simulated  $V_{OC}$  values obtained for the Au/Spiro-OMeTAD/MAPI/TiO<sub>2</sub>/FTO device structure, with and without the inclusion of C<sub>60</sub>-BA

Device	Technique	$V_{OC}$ with no mobile ions (V)	$V_{OC}$ with mobile ions (V)	$\Delta V_{OC}$ due to mobile ions (mV)
Without C <sub>60</sub> -BA	Simulation	0.88	0.99	110
	Experimental	0.84 ± 0.02	1.00 ± 0.01	160 ± 10
With C <sub>60</sub> -BA	Simulation	0.95	1.00	50
	Experimental	0.97	1.01 ± 0.02	40 ± 10

Next, we use our values of  $V_{flat}$  to identify the SaP  $JV$  with the most uniform mobile ion distribution and consider this to be an experimental measure of device performance in the absence of mobile ions. This allows us to plot experimentally obtained  $JVs$  which illustrate how device performance is altered by the presence of mobile ions. We show these in Fig. 2c and d for the cases without and with C<sub>60</sub>-BA, respectively. These plots demonstrate that the presence of mobile ions increases the  $V_{OC}$  of both devices (see also Table 1). When evaluated at  $V_{bias} \approx V_{flat}$ , the average of these increases are 160 ± 10 mV and 40 ± 10 mV for the devices without and with C<sub>60</sub>-BA, respectively (see Fig. S9 for how this difference varies with  $V_{bias}$ , ESI<sup>†</sup>). We see that the size of the  $V_{OC}$  improvement is smaller for the device with C<sub>60</sub>-BA, which is consistent with our hypothesis. However, this hypothesis was based on simulations which used idealised, symmetric devices. To verify that the insights from this simplified model apply to real PSCs, we performed explicit simulations of the MAPI devices shown in Fig. 2. In these simulations, we assumed that the effect of the C<sub>60</sub>-BA was to minimise surface recombination at the perovskite/ETL interface, without otherwise changing the device stack (*i.e.*, without the inclusion of an explicit C<sub>60</sub>-BA layer). We obtained an excellent agreement between the simulated and measured trends (see Table 1 and Supplementary Note Four, ESI<sup>†</sup>), demonstrating our model's applicability to complex experimental situations.

In addition to having a higher  $V_{OC}$ , Fig. 2e shows that the mean PCE of the QSS  $JVs$  is higher than that of the corresponding 'no mobile ions' SaP  $JVs$  evaluated at  $V_{flat}$ . This is even more striking when we consider the device-by-device data listed in Tables S3 and S4 (ESI<sup>†</sup>), which reveal that the same trend is found in every measured device bar one, where performance was comparable in the SaP and QSS  $JVs$ . To confirm that this effect is not limited to devices using TiO<sub>2</sub> as the ETL, we performed the same measurements on devices with SnO<sub>2</sub> in the place of TiO<sub>2</sub> and observed similar trends (see Supplementary Note Five, ESI<sup>†</sup>).

Thus, our results demonstrate that the presence of mobile ions can improve device performance in two commonly used device architectures. We note here that our results appear to contradict previous studies which compared fast and slow  $JV$  sweeps to assess PSC performance with and without mobile ions and observed no significant impact of ions on  $V_{OC}$ .<sup>10,11,57</sup> However, in these experiments, the device performance without mobile ions was assessed following a stabilisation period under illumination at open circuit, based upon the assumption that  $V_{OC}$  could be used as an approximate value for  $V_{flat}$  (*i.e.*, that a

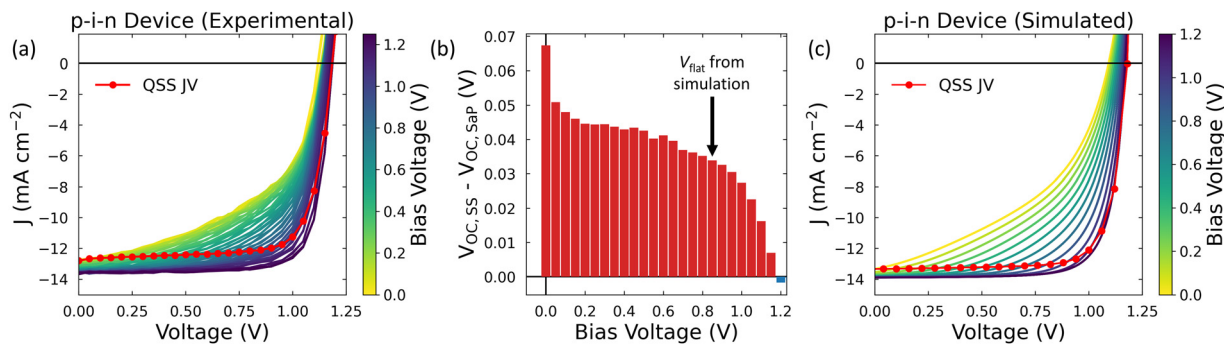
stabilisation period at  $V_{OC}$  would lead to a uniform ion distribution in the perovskite). However, as we have shown, this is generally not the case and  $V_{OC}$  is typically greater than  $V_{flat}$ , especially in p-i-n device structures, such as those used in refs 10,11,57 (see eqn (1) and Supplementary Note Three, ESI<sup>†</sup>). Consequently, such a stabilisation protocol will lead to a non-uniform ion distribution, with positive ionic charge accumulating by the ETL. A fast  $JV$  sweep performed from these starting conditions will not provide an accurate measurement of how the device would perform in the absence of mobile ions and will tend to overestimate the  $V_{OC}$  which could be achieved by the 'ion free' device due to the accumulated ionic charge displacing minority carriers at the perovskite/transport layer interfaces. In fact, the choice of  $V_{OC}$  as the stabilisation potential in ref. 10,11 and 57 meant that  $V_{OC}$  was predetermined to be identical for both the slow and fast  $JV$  measurements since the prebias potential defines the applied voltage at which the device configuration is identical in both scans. As a result, this measurement protocol gives no information about whether the distribution of ions at steady state influences  $V_{OC}$  relative to an equivalent device without mobile ions.

### Impact of mobile ions on hysteresis-free, high efficiency perovskite solar cells

Until now, we have focused on the pronounced effects of mobile ions in devices using MAPI as the active layer. However, the highest efficiency devices commonly use more complex perovskite compositions which have been reported to have lower concentrations of mobile ions.<sup>58</sup> Our simulations predict that the change in  $V_{OC}$  due to mobile ions decreases as the mobile ion concentration decreases (see Fig. 1b and c). This raises the question: are mobile ions relevant to the steady-state performance of the highest efficiency PSCs?

To address this question, we performed Stabilise and Pulse measurements on high efficiency, p-i-n devices which showed little  $JV$  curve hysteresis when measured at scans rates in the range 0.01–0.50 V s<sup>-1</sup> (PCE of 21.5% for the device shown in the text, see Fig. S10 for  $JV$  data, ESI<sup>†</sup>) with the structure Ag/BCP/PCBM/PEAI/perovskite/2PaCz/NiO<sub>x</sub>/ITO where the perovskite composition is Cs<sub>0.05</sub>(FA<sub>0.87</sub>MA<sub>0.13</sub>)Pb(I<sub>0.87</sub>Br<sub>0.13</sub>)<sub>3</sub> (see Fig. S6 for the device stack and Fig. S11 for the stabilisation data, ESI<sup>†</sup>). The full results are shown in Fig. 3a, where we have superimposed the QSS  $JV$  to allow for a direct comparison with the pulsed  $JV$  data. We have done this to illustrate the significant effect that the mobile ion distribution has on the shape of the  $JV$  curve, even in this "hysteresis-free" device. We also



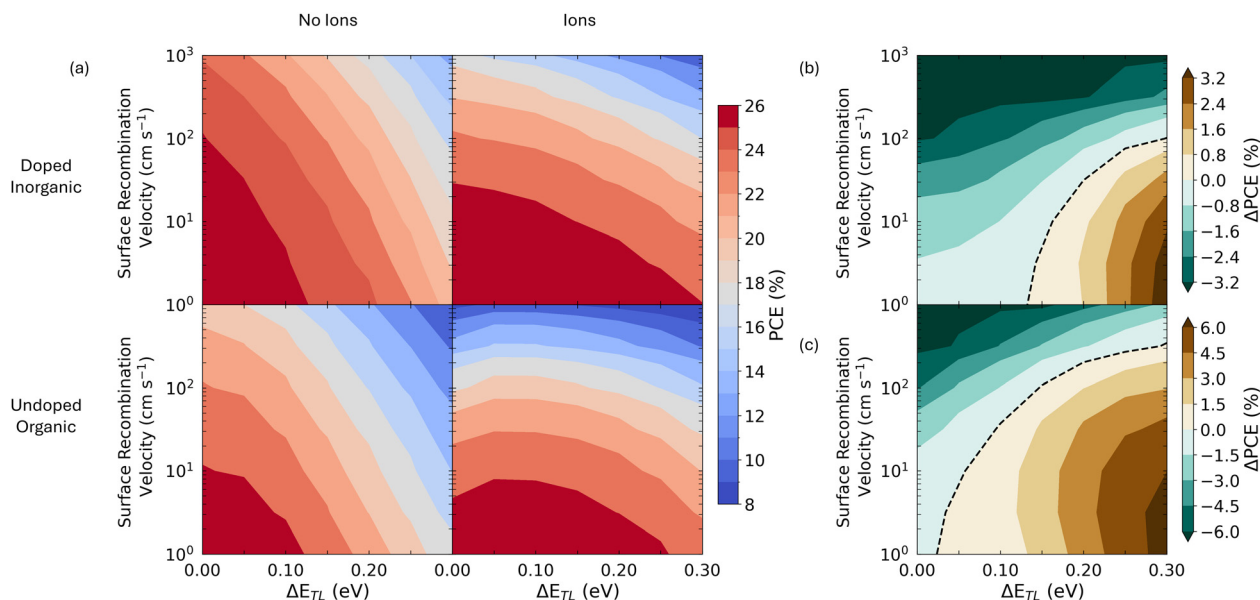


**Fig. 3** (a) Results of the Stabilise and Pulse measurement for a high efficiency p–i–n device (device structure shown in Fig. S6, ESI†). A light intensity of  $\sim 0.5$  Suns was used to prevent device degradation during the measurement (see Extended Methods). The red line indicates the quasi-steady state (QSS) JV, in which the ions are always in their dynamic-equilibrium distribution for the applied voltage. (b) Difference between the  $V_{OC}$  of the QSS JV and the stabilise and pulse (SaP) JVs for each applied prebias. The black arrow indicates the value of  $V_{flat}$  extracted from our simulations of this device. (c) Simulated Stabilise and Pulse data using parameters representative of the device stack shown in (a). By examining the simulated quasi-steady state JV, we identified that the ionic distribution was uniform at an applied bias of 0.85 V (see Fig. S13, ESI†). We note that this is less than the work function offset between the cathode and anode given in Table S5 (ESI†) (1.05 V), which is due to the undoped nature of the ETL (see eqn (1) and Supplementary Note Three, ESI†).

quantify the effect of mobile ions on  $V_{OC}$  as a function of  $V_{bias}$  (i.e., different ‘frozen ion’ distributions) by calculating the difference between  $V_{OC}$  at quasi steady state ( $V_{OC,SS}$ ) and that determined from the SaP JVs measurements for each value of  $V_{bias}$  ( $V_{OC,SaP}$ ). This is shown in Fig. 3b, which demonstrates that the presence of ions improves  $V_{OC}$  for  $V_{bias} < 1.20$  V (i.e., until  $V_{bias} \approx V_{OC,SS}$ ) and improves PCE for  $V_{bias} < 1.00$  V (see Fig. S12, ESI†).

Due to the small change in the gradient of the SaP JVs around  $V_{OC}$ , we did not rely solely on our experimental analysis to extract the value of  $V_{flat}$  for this device. We also performed

additional drift-diffusion simulations to identify this quantity using the parameter set listed in Table S5 (ESI†). As is shown in Fig. 3c, we could use these parameters to simulate Stabilise and Pulse measurements which showed a good quantitative agreement with the experimental data. This gives us confidence in the accuracy of our input parameters and thus the simulated  $V_{flat}$  value of 0.85 V (see Fig. S13, ESI†). We note that this value is comparable to that extracted from our experimental data ( $V_{flat} = 0.83$  V, see Fig. S14, ESI†) and to literature values for similar device stacks.<sup>37</sup> When we evaluate  $V_{OC,SS} - V_{OC,SaP}$  at this value of  $V_{flat}$  (indicated by the arrow on Fig. 3b), we find that



**Fig. 4** (a) A comparison of the dependence of PCE on surface recombination velocity and transport layer energetic offset ( $\Delta E_{TL}$ ) for simulated devices without (left-hand column) and with (right-hand column) a mobile ion density of  $10^{18} \text{ cm}^{-3}$ . In the top row, we show results for devices using the doped inorganic parameter set and, in the bottom row, we show results for devices using the undoped organic parameter set. Figures (b) and (c) show the difference in PCE, defined as  $\Delta PCE = PCE(\text{with ions}) - PCE(\text{no ions})$ , for (b) the doped inorganic parameter set and (c) the undoped organic parameter set. The black dashed line is a guide for the eye to indicate where  $\Delta PCE = 0$ .





the presence of mobile ions increases  $V_{OC}$  by approximately thirty millivolts in this class of high efficiency p-i-n devices, demonstrating that mobile ions remain relevant to the device physics of high performance PSCs.

### Impact of mobile ions on design rules for perovskite solar cells

Finally, we return to the question of what mobile ions mean for PSC efficiency more generally. To investigate this issue, we simulated  $JV$  curves as described above, but altered the perovskite layer parameters to match those described in ref. 2, in which devices achieved a certified efficiency of over 25% (see note under Table S2, ESI†). Using these  $JVs$ , we calculated PCEs as a function of  $v_s$  and  $\Delta E_{TL}$  for both transport layer parameter sets, as is shown in Fig. 4a. We find that the mobile ionic modulation of  $V_{OC}$  shifts the regions of parameter space where PSCs can obtain high PCEs. Specifically, Fig. 4a shows that the presence of mobile ions reduces the dependence of PCE on  $\Delta E_{TL}$ . This is because the redistribution of ions in these devices

suppresses surface recombination currents and allows them to maintain a high  $V_{OC}$ , even at large values of  $\Delta E_{TL}$  (see Fig. S15, ESI†). Thus, although the maximum achievable PCE is similar across all four simulations, devices containing mobile ions outperform those without at higher values of  $\Delta E_{TL}$  (see Fig. 4b and c). However, this improved tolerance to energetic offsets comes at the cost of a greater sensitivity to the rate of surface recombination, with devices containing mobile ions losing PCE more rapidly than those without as this parameter increases. Examining the  $JV$  parameters in detail (Fig. S15, ESI†), we see that this loss in PCE cannot be ascribed to just a single parameter, but that the presence of mobile ions makes all aspects of device performance degrade more rapidly as surface recombination velocity increases. Therefore, in the case of solar cells which contain a mobile ionic species, these results imply that greater gains in PCE can be made by passivating active layer/transport layer interfaces than by improving the energetic alignment between these layers. Based on the insights

**Table 2** Summary of the different device design parameters comparing equivalent devices with and without a mobile ionic species. The mobile ionic species is assumed to be confined to the active layer

Change in cell design parameter	Example	Relative impact of change in cell design parameter on photovoltaic performance	
		With ions	Without mobile ions
Reduce electron/hole diffusion length or increase perovskite thickness	Prolonged exposure of device to light <sup>67</sup>	<b>Loss in <math>J_{sc}</math></b> Ions screen the built-in potential, which leads to charge collection being driven by diffusion (Fig. 1a) <sup>11,12,68</sup>	<b>Loss in fill factor</b> Transport is drift-driven, charge collection efficiency is dependent on the applied field. (Fig. S16, ESI).
Reduce built-in potential (interface dominated recombination with low to medium rate)	Use gold as the metallic electrode in place of silver (for same device stack)	<b>Gain in <math>V_{OC}</math></b> Ionic charge substituted for minority electronic charge carriers at key interfaces. This results in lower recombination rates when $V > V_{flat}$ (Fig. 1b and c)	<b>Reduction in <math>V_{OC}</math></b> Minority electronic charge carriers accumulate at key interfaces. This results in a sharp increase in recombination rates when $V \leq V_{flat}$ . (Fig. 1b and c)
Reduce built-in potential (interface dominated recombination with high rate)		<b>Reduction in <math>V_{OC}</math></b> Ionic charge attracts minority electronic carriers to key interfaces. This increases recombination rates when $V < V_{flat}$ (Fig. S3, ESI)	<b>Gain in <math>V_{OC}</math></b> The internal electric field repels minority electronic carriers from key interfaces. This results in lower recombination rates when $V > V_{flat}$ (Fig. S3, ESI)
Reduce built-in potential (bulk dominated recombination, high injection limit, $n \approx p$ )		<b>Reduction in <math>J_{sc}</math> and <math>V_{OC}</math></b> Ionic field screening results in greater overlap of the electron and hole populations, increasing the rate of bulk recombination processes (Fig. S3, ESI).	<b>Gain in <math>J_{sc}</math> and <math>V_{OC}</math></b> Presence of an electric field in the active layer reduces overlap of the electron and hole populations, decreasing the rate of bulk recombination processes (Fig. S3, ESI)
Increase energy offset between perovskite and transport layer band edges	Replace PCBM electron transport layer with $C_{60}$	<b>Effect similar to reducing the built-in potential, refer to the relevant row above.</b> For undoped organic transport layers, cell efficiency increases for moderate offsets due to improved extraction and smaller $V_{OC}$ losses (Fig. S17, ESI).	For undoped organic transport layers, negligible improvement in efficiency for moderate offsets due to efficient extraction and larger $V_{OC}$ losses (Fig. S17, ESI).
Dope perovskite layer	Vary perovskite precursor ratio <sup>69</sup>	All factors described above show reduced sensitivity to mobile ions due to the greater contribution of electronic charge to the perovskite layer electrostatics <sup>28</sup>	
Asymmetry in contact layer energetic offsets	Use <i>e.g.</i> , PTAA with ICBA as the charge transport layers	Asymmetric redistribution of ionic charge and injection of electronic charge from contacts results in effective doping of the perovskite bulk by uncompensated mobile ions. All factors described above show less sensitivity to mobile ions (Supplementary Note One, ESI) <sup>28,31</sup>	



from the validated simulations presented here and previous results, we believe that this is one of several ways in which the design criteria for solar cells with and without a mobile ionic species differ. We summarise these differences in Table 2, which describes how the presence of mobile ionic charge influences the performance of a perovskite solar cell as different cell design parameters are changed relative to an equivalent device without mobile ions.

## Conclusions

We have shown that the presence of mobile ions does not *a priori* reduce the maximum achievable efficiency of PSCs but does change the design regime where this maximum efficiency is attained. Using drift-diffusion simulations, we demonstrate that this is because the size of interfacial recombination currents in PSCs are less sensitive to energetic misalignments at perovskite/transport layer interfaces than in equivalent devices with no mobile ions, provided that  $V_{OC}$  exceeds the flat band condition in the perovskite layer. This increases the range of energetic offsets for which PSCs can maintain high PCEs, although it makes them less tolerant to high values of the surface recombination velocity, which explains the field's focus on minimising interfacial recombination in recent years. Additionally, this is the first experimental demonstration that the presence of mobile ions systematically increases steady-state  $V_{OC}$  relative to devices without mobile ions. This result was found to hold for devices using n-i-p and p-i-n architectures, with MAPI or alloyed perovskite compositions, and using a range of possible transport layer materials. Most importantly, we have shown that the effects of mobile ions are still relevant in determining the steady-state performance of highly efficient PSCs, even those which show negligible hysteresis. The close agreement of our experimental and simulated results confirms the validity of drift-diffusion simulations in describing the device physics of PSCs and provides strong evidence for our claim that mobile ions are not necessarily detrimental to the performance of PSCs. Instead, their impact on steady state PCE should be considered holistically, since it is possible for losses in photocurrent caused by ionic field screening to be compensated for by ion-mediated gains in photovoltage.

## Author contributions

L. J. F. H, P. C. and P. R. F. B. conceived the ideas. L. J. F. H. performed the drift-diffusion and interpreted simulations under the supervision of J. R. D. and P. R. F. B. Stabilise and Pulse measurements were performed by F. J. A. under the supervision of P. D. Triple cation perovskite solar cells were fabricated by Y. L and A. K under the supervision of A. B. D. L. J. F. H wrote the manuscript. All authors discussed the results and reviewed the manuscript.

## Data availability

Data used to generate the main text figures in this article are available at <https://doi.org/10.5281/zenodo.12761597>. The Driftfusion code used in this paper can be found at <https://github.com/lucy-hart/Driftfusion/tree/MobileIonsImproveTheDesignTolerancesOfPSCs>. The parameters used in generating the simulation results have been included as part of the ESI† and can also be found in the Input\_files folder of the above link.

## Conflicts of interest

There are no conflicts to declare.

## Acknowledgements

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